

Drawings

1. The drawing filed on 11/5/09 is accepted by the examiner.

Allowable Subject Matter

2. The following is an examiner's statement of reasons for allowance:

The Mino reference (US 2003/0118897) discloses a method of producing a lithium microbattery comprising formation of first and second current collectors "b" & "g", a cathode, an electrolyte comprising a lithiated compound, and an anode comprising lithium "f" on a substrate "a1", wherein the electrolyte formation step comprises the steps: depositing the electrolyte layer on a substrate provide with a current collector and with a first active material layer, wherein the electrolyte layer is formed by photoresist coating and the dry-etching method which implies that a photoresist (mask) is fabricated by photolithography on the electrolyte layer, unnecessary portions are removed by dry-etching, and then the photoresist is removed to form the electrolyte (See paragraph [0017],[0019], [0046],[0047] and Figures 6-9).

However, Mino et al does not expressly teach the step of: depositing, on the electrolytic thin layer, a first protective thin layer that is chemically inert with regard to lithium and then a first masking thin layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

TC

/Jonathan Crepeau/
Primary Examiner, Art Unit 1795